

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Appl. No. : 10/537,363 Confirmation No. 3423
Applicant : Wieve DE BOER
Filed : June 2, 2005
TC/A.U. : 1763
Examiner : NG, James Wai Heung

Docket No. : US02 0527 US
Customer No. : 65913

Title: SYSTEM AND METHOD FOR SUPPRESSION OF WAFER TEMPERATURE DRIFT IN COLD-WELL CVD SYSTEMS

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

RESPONSE & AMENDMENT

Sir:

In response to the Office Action of September 24, 2007, please consider the following:

Amendments to the Specification there are no amendments in this paper.

Amendments to the Claims begin on page 2 of this paper.

Remarks/Arguments begin on page 4 of this paper.